

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Patent Application

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Case 46-19-123

Serial No. 09/516004

Group Art Unit 2811

Filing Date February 29, 2000

Examiner O. Nadav

Title Selective Laser Anneal On Semiconductor Material

ASSISTANT COMMISSIONER FOR PATENTS  
WASHINGTON, D. C. 20231

SIR:

ELECTION OF CLAIMS

In response to the Official Action of March 7, 2001, Applicant hereby elects to prosecute Group I, Claims 6-11, with traverse. It is submitted that the inventions of Groups I and II are not distinct because the process of Group II does not require providing dopant to spaced apart regions after forming a FET gate structure. Process claims are not limited to the sequence of recitation unless expressly stated in the claims. Withdrawal of the restriction requirement is required.

Respectfully Submitted,

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Dated: 4/6/01

I hereby certify that this correspondence is being deposited with the United States Postal Service as first class mail in an envelope addressed to: Commissioner of Patents and Trademarks Washington, D.C. 20231 on  
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